Slow magnetic relaxation in Tb(III)-based coordination polymer

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La…O model



La-N: ~2.803 Å, La-O: ~2.593 Å

Figure S1. Optimized structure of the model.

х	У	Z
-1.44839	2.01626	-1.35746
-2.80803	-0.00036	-0.00098
-1.44887	-2.01735	1.35581
1.16693	1.68318	-1.59223
1.1665	-1.68485	1.59115
-0.00007	-0.00052	-0.0004
1.4474	1.76437	1.67004
1.44858	-1.765	-1.67023
2.80733	-0.0001	0.00021
-1.16723	1.39523	1.8475
-1.16618	-1.39701	-1.84832

Table S1. T	The coordinates	for model
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Figure S2. EXAFS oscillation of polyTb.



Figure S3. The magnetization vs. field plots for polyTb.



Figure S4. (a) χ " vs. T plots for **polyTb** in various field in solid at 2 K; (b) External field dependent of τ values of **polyTb** in various field in solid at 2 K.



Figure S5. Cole–Cole plots for polyTb in various field in solid at 2 K



Figure S6. The relaxation time for polyTb.



Figure S7. χ " vs. T plots for **polyTb** in a field of 3000 Oe in solid and solution at 2 K.



Figure S8. Excitation spectra of polyTb probed at 640 nm at RT and 77 K.



Figure S9. XRD pattern of **polyTb**: blue: on Si (diffraction at 33 degree is comes from Si substrate); red: on glass; black: powder.